

We claim:-

1. The use of copolymers containing units derived from at least 2 monoethylenically unsaturated monomers B1 and B2 which each contain at least one nitrogenous heterocycle, as auxiliaries for textile dyeing and textile printing.
5
2. The use of claim 1, wherefor the auxiliaries for textile dyeing are selected from the group consisting of stripping agents, leveling agents and aftersoaping agents.
10
3. The use of claim 1 or 2, wherefor at least one copolymer is a graft polymer.
4. The use of claim 3, wherefor at least one graft polymer is constructed from
15 a polymeric grafting base A which contains no monoethylenically unsaturated units, and
polymeric side chains B formed from copolymers of at least two
monoethylenically unsaturated monomers B1 and B2 which each contain at least
20 one nitrogenous heterocycle and optionally further comonomers B3.
5. The use of claim 3 or 4, wherefor said side chains B account for more than 35% by weight fraction of said graft polymer.
- 25 6. The use of any of claims 3 to 5, wherein said polymeric grafting base A is a polyether.
7. Auxiliaries for textile dyeing and textile printing as set forth in any of claims 1 to 6.
30
8. Stripping agents containing at least one copolymer containing units derived from at least 2 monoethylenically unsaturated monomers B1 and B2 which each contain at least one nitrogenous heterocycle.
- 35 9. Stripping agents as claimed in claim 8, wherein said copolymer is a graft copolymer.
- 40 10. A process for stripping off-shade dyeings off textile materials, which comprises using a stripping agent comprising at least one copolymer which contains units derived from at least 2 monoethylenically unsaturated monomers B1 and B2 which each contain at least one nitrogenous heterocycle.

11. A process as claimed in claim 9, wherein at least one copolymer is a graft polymer.
- 5 12. Leveling agents comprising at least one copolymer which contains units derived from at least 2 monoethylenically unsaturated monomers B1 and B2 which each contain at least one nitrogenous heterocycle.
- 10 13. Leveling agents as claimed in claim 12, wherein at least one copolymer is a graft polymer.
- 15 14. A process for leveling dyeings on textile materials, which comprises using a leveling agent comprising at least one copolymer which contains units derived from at least 2 monoethylenically unsaturated monomers B1 and B2 which each contain at least one nitrogenous heterocycle.
- 20 15. A process as claimed in claim 14, wherein at least one copolymer is a graft polymer.
- 25 16. Aftersoaping agents comprising at least one copolymer which contains units derived from at least 2 monoethylenically unsaturated monomers B1 and B2 which each contain at least one nitrogenous heterocycle.
- 30 17. Aftersoaping agents as claimed in claim 16, wherein at least one copolymer is a graft polymer.
- 35 18. A process for afterclearing dyed or printed textile, which comprises using at least one copolymer containing units derived from at least 2 monoethylenically unsaturated monomers B1 and B2 which each contain at least one nitrogenous heterocycle.
- 40 19. A process as claimed in claim 18, wherein at least one copolymer is a graft polymer.
20. A process as claimed in claim 19, wherein at least one graft polymer is constructed from
- a polymeric grafting base A which contains no monoethylenically unsaturated units, and
- polymeric side chains B formed from copolymers of at least two

monoethylenically unsaturated monomers B1 and B2 which each contain at least one nitrogenous heterocycle and optionally further comonomers B3.

- 5 21. A process as claimed in claim 19 or 20, wherein said side chains B account for a more than 35% by weight fraction of said graft polymer.
22. A process as claimed in any of claims 18 to 21, wherein said polymeric grafting base A is a polyether.
- 10 23. A process as claimed in any of claims 18 to 22, which further comprises using at least one further component selected from complexing agents and nonionic surfactants.
- 15 24. A process as claimed in any of claims 18 to 23, operated at weakly acidic to neutral pH.